

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L1	1218	(photoacid adj generat\$4 or photo adj acid adj generat\$4) same (sulfonium or thionium) and (resist or photoresist)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	ON	2005/12/07 07:15
L2	618	sulfonium same (conjugated or benzoyl)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	ON	2005/12/07 07:15
L3	0	"l21" and l1	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	ON	2005/12/07 07:15
L4	37	l2 and l1	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	ON	2005/12/07 07:15
S1	759	fumiuyuki near nishiyama.in. or kenichiro near sato.in. or kunihiho near kodama.in.	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2005/12/05 14:44
S2	366	(fumiuyuki near nishiyama.in. or kenichiro near sato.in. or kunihiho near kodama.in.) and resist	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2005/05/05 13:34
S3	146	(fumiuyuki near nishiyama.in. or kenichiro near sato.in. or kunihiho near kodama.in.) and resist and alicyclic	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2005/05/05 13:34
S4	140	(fumiuyuki near nishiyama.in. or kenichiro near sato.in. or kunihiho near kodama.in.) and resist same composition and alicyclic	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2005/05/05 13:34
S5	93	(fumiuyuki near nishiyama.in. or kenichiro near sato.in. or kunihiho near kodama.in.) and positive adj resist same composition and alicyclic	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2005/05/05 14:46
S6	93	(fumiuyuki near nishiyama.in. or kenichiro near sato.in. or kunihiho near kodama.in.) and positive adj resist same composition and alicyclic	US-PGPUB; USPAT; EPO; JPO	OR	ON	2005/05/05 15:35
S7	7	("6159656" "6511787" "6596458" "6630280" "6692884" "6699635" "6787283").PN.	US-PGPUB; USPAT; USOCR	OR	OFF	2005/05/05 14:51
S8	7	("6013416" "6087063" "6207342" "6280898" "6291130" "6303266" "6348297").PN.	US-PGPUB; USPAT; USOCR	OR	OFF	2005/05/05 15:17
S9	370	(positive same (photo adj resist or photoresist)).ti.	US-PGPUB; USPAT; USOCR	OR	OFF	2005/05/05 15:18
S10	854	(positive same (photo adj resist or photoresist)).ab.	US-PGPUB; USPAT; USOCR	OR	OFF	2005/05/05 15:18
S11	1911	(positive same (photo adj resist or photoresist)).clm.	US-PGPUB; USPAT; USOCR	OR	OFF	2005/05/05 15:24
S12	2183	(S9 or S10 or S11)	US-PGPUB; USPAT; USOCR	OR	OFF	2005/05/05 15:18

S13	0	S12 and alicyclic adj2 (acrylate or methacrylate)	US-PGPUB; USPAT; USOCR	OR	OFF	2005/05/05 15:19
S14	4	S12 and alicyclic adj2 (acrylate or methacrylate)	US-PGPUB; USPAT; USOCR	OR	OFF	2005/05/05 15:19
S15	21	S12 and alicyclic adj2 (acrylate or methacrylate)	US-PGPUB; USPAT; USOCR	OR	ON	2005/05/05 15:19
S16	21	S12 and alicyclic adj2 (acrylate or methacrylate)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	ON	2005/05/05 15:25
S17	36588	(positive same (resist or photoresist))	US-PGPUB; USPAT; USOCR	OR	OFF	2005/05/05 15:25
S18	3061	(positive same (resist or photoresist)).clm.	US-PGPUB; USPAT; USOCR	OR	OFF	2005/05/05 15:25
S19	1610	(positive same (resist or photoresist)).ab.	US-PGPUB; USPAT; USOCR	OR	OFF	2005/05/05 15:25
S20	722	(positive same (resist or photoresist)).ti.	US-PGPUB; USPAT; USOCR	OR	OFF	2005/05/05 15:25
S21	3574	S18 or S19 or S20	US-PGPUB; USPAT; USOCR	OR	OFF	2005/05/05 15:25
S22	26	S21 and alicyclic adj2 (acrylate or methacrylate)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	ON	2005/05/05 15:25
S23	5	S22 not S16	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	ON	2005/05/05 15:26
S24	258	(methyldecahydronaphthyl or methyl adj decahydronaphthyl or methylcyclohexyl or methyl adj cyclohexyl or methylcyclooctyl or methyl adj cyclooctyl or cyclo adj octyl) adj (acrylate or methacrylate)	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	OFF	2005/06/07 09:06
S25	19	S24 and photoresist	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	OFF	2005/06/07 09:50
S26	4602	photoacid adj generat\$4 or photo adj acid adj generat\$4	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2005/06/07 09:51
S27	3789	(photoacid adj generat\$4 or photo adj acid adj generat\$4) and (resist or photoresist)	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2005/06/07 09:52
S28	1495	S27 and (sulfonium or thionium)	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2005/06/07 09:52
S29	1112	(photoacid adj generat\$4 or photo adj acid adj generat\$4) same (sulfonium or thionium) and (resist or photoresist)	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2005/12/07 07:13

S30	799	(photoacid adj generat\$4 or photo adj acid adj generat\$4) same (sulfonium or thionium) and (resist or photoresist).clm.	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2005/06/07 09:53
S31	867	(photoacid adj generat\$4 or photo adj acid adj generat\$4) same (sulfonium or thionium) and (resist or photoresist).ab.	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2005/06/07 09:53
S32	753	(photoacid adj generat\$4 or photo adj acid adj generat\$4) same (sulfonium or thionium) and (resist or photoresist).ti.	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2005/06/07 09:53
S33	927	S30 or S31 or S32	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2005/06/07 09:53
S34	33	S33 and alicyclic	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2005/06/07 10:39
S35	49	"292917"	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2005/06/07 10:40
S36	3	"2000292917"	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2005/06/07 10:45
S37	2	"2001294570"	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2005/06/07 11:43
S38	3	"11119434"	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2005/06/07 10:51
S39	3	"11119434" and acid adj generat\$4	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2005/06/07 10:57
S40	10	"973173"	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2005/06/07 10:59
S41	0	"199773173"	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2005/06/07 10:59
S42	3	"0973173"	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2005/06/07 10:59
S43	0	"1997973173"	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2005/06/07 11:00
S44	0	"199773173"	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2005/06/07 11:04

S45	7	"09073173"	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2005/06/07 11:04
S46	4	"6528232"	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2005/06/07 12:07
S47	2	("5919596" "6528232").PN.	US-PGPUB; USPAT; USOCR	OR	OFF	2005/06/07 11:46
S48	2	"6733951"	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2005/06/07 12:50
S49	1	"6440636" and surfactant	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2005/06/07 13:31
S50	2	"6733951"	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2005/06/07 13:31
S51	9818	positive adj resist	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2005/12/05 14:44
S52	3421	alicyclic with (acrylate or methacrylate)	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2005/12/05 14:48
S53	246	S51 and S52	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2005/12/05 15:02
S54	142554	adamantyl or noradamantyl or adecyl or atricyclodecanyl or atetracyclodecanyl or cyclododecanyl or cyclohexyl or cycloheptyl or anorbornyl or acedrol or cyclodecanyl near5 (acrylate or methacrylate)	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2005/12/05 15:05
S55	1206	S51 and S54	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2005/12/05 15:07
S56	279	S55 and acid adj decomposable	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2005/12/05 15:08
S57	37	S56 and sulfonium adj compound	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2005/12/05 15:08